

PATENT ABSTRACTS OF JAPAN

(11)Publication number : 02-002515

(43)Date of publication of application : 08.01.1990

(51)Int.Cl.

G02F 1/1337
G02F 1/1337

(21)Application number : 63-148542

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(22)Date of filing : 16.06.1988

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(54) MANUFACTURE OF ORIENTING FILM FOR LIQUID CRYSTAL

(57)Abstract:

PURPOSE: To increase the pretilt angle of liquid crystal molecules by irradiating the main surface of a substrate provided with an X-ray resist layer with a parallel X rays at a specific angle and then dipping the substrate in a liquid developer and rinsing liquid.

CONSTITUTION: The main surface of the substrate 15 provided with the X-ray resist layer 14 is irradiated with the parallel X rays at the specific angle α and then dipped in the liquid developer and rinsing liquid. The X rays are an electrode wave whose wavelength is 0.1-50 μ m; and a soft X rays (4-50 μ m; wavelength) is easy to use. The X-ray resist layer 14 is exposed to the X rays and dipped in the liquid developer and rinsing liquid to have an irregular X-ray resist layer, so that the liquid crystal molecules are oriented. Then the X rays are projected slantingly to obtain a saw-tooth X-ray resist layer. Consequently, the pretilt angle of the liquid crystal molecules is increased.

